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Published in:
Physical Review B

Link to article, DOI:
10.1103/PhysRevB.93.245415

Publication date:
2016

Document Version
Publisher's PDF, also known as Version of record

Link back to DTU Orbit

Citation (APA):
Inelastic vibrational signals in electron transport across graphene nanoconstrictions

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(Received 12 April 2016; revised manuscript received 1 June 2016; published 16 June 2016)

We present calculations of the inelastic vibrational signals in the electrical current through a graphene nanoconstriction. We find that the inelastic signals are only present when the Fermi-level position is tuned to electron transmission resonances, thus, providing a fingerprint which can link an electron transmission resonance to originate from the nanoconstriction. The calculations are based on a novel first-principles method which includes the phonon broadening due to coupling with phonons in the electrodes. We find that the signals are modified due to the strong coupling to the electrodes, however, still remain as robust fingerprints of the vibrations in the nanoconstriction. We investigate the effect of including the full self-consistent potential drop due to finite bias and gate doping on the calculations and find this to be of minor importance.

DOI: 10.1103/PhysRevB.93.245415

I. INTRODUCTION

Graphene is foreseen to become a versatile material with a wide range of applications in nanoelectronics [1–3]. Much research addresses the phonon-limited electron mobility of pristine devices [4,5]. However, the properties related to electron-phonon coupling in nanoscale devices based on nanostructured graphene has received much less attention [6,7]. Nanostructuring of graphene may play a key role in making graphene applicable in electronics since it provides a direct way for tuning the band gap [8,9], guiding electrons [10–12], as well as tuning the thermal properties [13–16]. Graphene nanoconstrictions (GNCs) are a generic example of nanostructured graphene that is used for semiconducting interconnects in graphene nanocircuitry [17,18] and may become a central building block of graphene-based nanoelectronics. State-of-the-art experiments have “sculpted” monolayer graphene with close to atomic precision down to a width of a few benzene rings [19,20]. In addition, a recent experiment indicates how one can control both width and edge morphology of nanoribbons through advances in bottom-up fabrication [21]. With the emergence of nanosized constrictions the current density can locally be very high, and it is important to address the coupling between current and localized vibrations in the device [7].

Recently, several papers have examined inelastic signals due to vibrational excitations in the second derivative of the current-voltage characteristics, so-called inelastic electron transport spectroscopy (IETS), of gated pristine graphene [22–27], and heterostructures of graphene and hexagonal boron nitride [28,29]. With the rapid development in fabrication and electronic characterization of nanostructured graphene [19,20,30] it is interesting to investigate the presence of inelastic vibrational signals for GNCs.

Carbon nanosystems, unlike metallic contacts, have electronic states that vary on the energy scale of the vibrational frequencies necessitating calculations which go beyond the otherwise successful wideband approximated lowest-order expansion (LOE-WBA) [31–33]. In the LOE-WBA one assumes a constant/energy-independent electronic structure and evaluates all electronic parameters at the Fermi level. However, phonon frequencies in graphene-based devices can approach 0.2 eV on which scale the electronic structure is varying significantly. Hereby it is important to encompass the difference in the electronic states before and after scattering from a vibration. We have recently developed an extended lowest order expansion (LOE) method that can include the rapid variation near resonances in the electronic spectrum with energy in IETS modeling [34]. This method enables studies of IETS on gated graphene nanostructures. IETS was originally developed to probe molecules on surfaces with scanning tunneling microscopy that are weakly bound to the leads [35] therefore possessing a set of localized vibrations. In the case of nanostructured graphene the vibrations of the device are strongly coupled with phonons in both leads, and the resulting lifetime broadening needs to be included in a predictive description of the inelastic transport signals [36,37]. The so-called propensity rules, approximate selection rules related to the symmetry of vibrational modes and electronic states of the junction, explain why only a few of many possible vibrational modes yield an inelastic signal [38–41]. The lifetime broadening could be severe and therefore needs to be considered in strong-coupled devices.

In this paper, we apply the extended LOE method [34] to describe the inelastic vibrational signals in the current for a GNC near an electronic resonance in the constriction. Contrary to, e.g., molecules coupled to metal electrodes [34], the main vibrational modes in the GNC have behavior and frequencies similar to those in the electrodes and are not merely localized in the junction. Therefore it is of special importance to include the coupling of these to the electrode phonons in the graphene leads and in particular take the damping due to this coupling into account in the IETS. We show how the IETS signals are broadened by this coupling which in turn gives rise to an additional selection of signals that can show up. The simulations are performed with density functional theory (DFT) and nonequilibrium Green’s functions (DFT-NEGFs).
packages [42–45] in combination with inELASTICA [44]. In addition, we have implemented both the LOE-WBA and the LOE methods in the ATOMIX TOOLKIT (ATK) simulation tool [46] to be able to compare the two methods. We find consistent results with both inELASTICA and ATK which strengthens the reproducibility of the results. We identify a number of inelastic vibrational signals in the current which persists including the strong coupling to electrode phonons in the GNC. We furthermore determine the impact on the IETS signals of finite bias and charge doping due to gate electrodes in the self-consistent calculation of the Hamiltonian.

II. SYSTEM AND METHOD

We consider the GNC system illustrated in Fig. 1(a) where the current is passed through a short ribbon [21,47–49] at the narrowest point that connects two graphene electrodes.

Looking at the transmission probability for an electron to cross the device, Fig. 1(b), we find that several electronic resonances are present due to the diffraction barrier at abrupt interfaces in graphene [12,50]. This diffraction barrier height is controlled by the width of the constriction. Making the constriction longer will move the peaks down in energy while maintaining the overall features. Here we choose a length where inelastic calculations are computationally heavy but still feasible. A gate electrode can be used to control the Fermi level and electronic states involved in the transport. Clearly the transmission probability, Fig. 1(b), varies significantly on the scale of typical optical phonon frequencies (0.2 eV).

The basis of the LOE method is the Meir-Wingreen formula for the electron current where one in addition applies a set of closed Dyson and Keldysh equations by replacing the full Green’s function with the single-particle Green’s function [34]. The equations are expanded to lowest order in the electron-phonon coupling matrix ($M^\lambda$) in the device region and simplified to describe the IETS signals using the fact that these are prominent only close to the excitation threshold where the applied bias equals the vibrational energy $V_b = \mu_L - \mu_R = \pm \omega_o$. Here $\mu_{L/R}$ are the chemical potentials of the left/right electrodes, and $\omega_o$ is the vibrational energy (we employ atomic units unless explicitly stated $\hbar = \varepsilon = 1$). The LOE expression for the second derivative of the current $I$ for a given mode $\lambda$ is a sum of two analytical functions [34],

$$\frac{\partial^2 I}{\partial V^2} = \gamma_e \frac{\partial}{\partial V} T^{\text{sym}}(V, \omega_o, T) + \kappa \frac{\partial}{\partial V} T^{\text{asym}}(V, \omega_o, T),$$  

where

$$T^{\text{sym}} = \frac{G_0}{2} \sum_{\sigma = \pm} \sigma(\omega_\sigma + \sigma V) \times \left( \coth \frac{\omega_\sigma}{2k_B T} - \coth \frac{\omega_\sigma + \sigma V}{2k_B T} \right).$$  

and

$$T^{\text{asym}} = \frac{G_0}{2} \int_{-\infty}^{\infty} d\epsilon \mathcal{H}(f(\epsilon') - f(\epsilon))(\epsilon) \times [f(\epsilon - eV) - f(\epsilon)],$$

where $f$ is the Fermi-Dirac function, $\epsilon' = \epsilon \pm \omega$, $\mathcal{H}$ denotes the Hilbert transform, and $G_0$ is the conductance quantum. The prefactors can be expressed in terms of the unperturbed retarded/advanced Green’s function $G^{r/a}$ and the (time-reversed) spectral density matrices $A_\sigma = G^a G^r$ ($\tilde{A}_\sigma = G^a G_r G^r$) and only involve evaluations of these quantities at the chemical potentials for the corresponding excitation threshold ($\mu_{L/R} = \pm \omega_o$). We have $\gamma_{\lambda} = \gamma_{e,\lambda} + \gamma_{\epsilon,\lambda}$ with $\gamma_{e,\lambda} \approx \text{Im } B_\lambda$, $\kappa \approx \text{Re } B_\lambda$,

$$\gamma_{\epsilon,\lambda} = \text{Tr}[M^\lambda \tilde{A}_\lambda(\mu_L) M^\lambda A_\lambda(\mu_R)],$$

and

$$B_\lambda = \text{Tr}[M^\lambda A_\lambda(\mu_L) \Gamma_L(\mu_L) G^r(\mu_L) M^\lambda A_\lambda(\mu_R) - M^\lambda G^{a}(\mu_R) \Gamma_L(\mu_R) A_\lambda(\mu_R) M^\lambda A_\lambda(\mu_L)].$$

The first part Eq. (4) is related to the Fermi’s golden rule rate of scattering from an incoming state with energy $\epsilon$ to a final state.
with energy $\varepsilon_k$. However, the dependence on energy is more complicated for the remaining interference terms Eq. (5).

These results are based on a noninteracting (infinite lifetime) phonon spectral density given by

$$A(\omega) = 2\pi \sum_\lambda |\mathcal{L}(\omega - \omega_\lambda) - \mathcal{L}(\omega + \omega_\lambda)|,$$  \hspace{1cm} (6)

with $\mathcal{L}(\omega) = \delta(\omega)$ for zero temperature and zero coupling to the electrodes. The phonon self-energy $\Pi_{ph}$ accounts for the coupling of the device to the phonon modes in the semi-infinite graphene leads and was calculated by a finite difference calculation of the force constants in a supercell together with an iterative procedure for calculating the surface phonon Green’s function [6]. The broadening of the vibrational density of states from coupling of the local device vibrations with bulk electrode phonons can be included as a postprocessing for each mode by convoluting the $\delta^2 I(V)$ signal with the device vibrational spectral function including the coupling to the electrode phonons. This can be seen using the Lehmann representation, see Viljas et al. [51]. In the simplest case we may use a Lorentzian broadened $\delta$ function,

$$\mathcal{L}_{\text{fric}}(\omega) = V_{SD} = \frac{1}{\pi} \frac{\eta_{ph}/2}{(\eta_{ph}/2)^2 + V_{SD}^2},$$  \hspace{1cm} (7)

to obtain the signal at the threshold voltage as

$$\delta^2 I(V) = \int dV' \delta^2 I(V') \mathcal{L}(V - V').$$  \hspace{1cm} (8)

The broadening, or linear friction coefficient, can be calculated from the diagonal elements of the phonon self-energy due to the coupling with the leads $\eta_{ph} = -\frac{i}{\omega} \text{Im} \left[ \Pi_{ph}^\text{ret} \right]_{\omega = 0}$. Alternatively, we may use the actual phonon DOS of each mode,

$$\mathcal{L}_{\text{DOS}}(\omega) = \text{DOS}(\lambda, \omega) = -\frac{2\omega}{\pi} \text{Im} \left[ \mathbf{D}_{\lambda, \omega}^\text{ret} \right].$$  \hspace{1cm} (9)

where we made use of the phonon retarded Green’s function $\mathbf{D}^\text{ret}$ expressed in the phonon mode eigenspace. The broadening in Eq. (9) has a more complex line shape than the Lorentzian but is guaranteed to reproduce all features in the total phonon DOS $\sum_\lambda \text{DOS}(\lambda, \omega)$. The convolution of the signals in Eq. (8) will be performed with both of the broadening models in Eqs. (7) and (9) for comparison.

In Fig. 1(c), we compare the DOS found from NEGF, cf. Eq. (9), with that of the friction model using the approximate self-energy $\Pi_{ph}^\text{ret} = -\frac{i}{\omega} \text{Im} \left[ \Pi_{ph}^\text{ret} \right]_{\omega = 0}$ in accordance with the Lorentzian broadening in Eq. (7) to substantiate our broadening models. The friction model is able to capture most key signatures in the DOS [52], such as peak positions and the underlying envelope shape which is an indication of the broadening at each frequency. The presence of narrow peaks in the DOS indicates localized vibrations in the constriction despite the strong contact with the graphene leads. In the next section, we will examine how the vibrations interact with the current.

### III. INELASTIC SIMULATIONS AND RESULTS

We now apply the widely used model gate where one simply tunes the Fermi-level $\mu_F$ through the electronic spectrum. We start by analyzing results neglecting the phonon broadening from the electrodes. In Fig. 2 the results from the LOE are presented and compared to that of the original LOE-WBA where all electronic parameters are evaluated at the equilibrium chemical potential.

We compare two situations: One where the system is gated close to the resonance ($\mu_F \approx \pm 0.6$ eV), Fig. 2(a), or one where the system is gated to a chemical potential where the electronic structure is effectively energy independent within the scale of phonon frequencies ($\mu_F \approx \pm 0.85$ eV), Fig. 2(b). On- and off-resonance positions are also indicated by arrows in Fig. 1(b). At resonance, see Fig. 2(a), the spectrum changes quite remarkably between the two models. The LOE method gives rise to several dip-peak features not present in the original LOE-WBA model. Within the LOE-WBA...
the electron-phonon coupling seems artificially strong, i.e., the change in conductance is larger than a few percent. The LOE gives a significantly lower signal which is related to the difference in density of states for the initial and final states. Tuning the energy away from the resonance ($\mu_f \approx \pm 0.85$ eV), the LOE model gives results consistent with the LOE-WBA, Fig. 2(b). The IETS signal undergoes a sign change from peaks off-resonance to dips at resonance, consistent with previous single-level model considerations [38,39]. In addition, we have shown the results obtained from the LOE implemented in ATK Figs. 2(a) and 2(b). In general, we find good agreement between the two implementations. The same signals are present in both calculations with differences in peak position and intensity being related to a slight variation in the equilibrium lattice constant in the two DFT codes using different pseudopotentials.

We will next analyze the origin of the five distinct peaks at resonance where the strongest interacting modes are located around 170 meV. The eight phonon modes with the largest inelastic signal are illustrated in Fig. 2(c). The contributing modes are the same within both LOE-WBA and LOE, although the LOE signal is clearly different. Since the current mainly runs through the $\pi$ orbitals, we expect the current to interact the strongest with longitudinal modes in the device plane. Due to the symmetry plane the Hamiltonian is the same for planar graphene nanostructures whether we move atoms up or down in the out-of-plane direction. Therefore, the out-of-plane electron-phonon coupling elements between $\pi$ orbitals will be zero, and the characteristic vibrations found for the GNC are all in-plane modes as expected. Comparing the scattering state symmetry at resonance, Fig. 1(a) and repeated inside the constriction in Fig. 2(c), it is evident that these modes all have displacement in the regions where the scattering state and current density are largest, i.e., near the ribbon edge of the entrance to the constriction or near the center of the ribbon.

With an explanation of the vibrational signals near and far from resonance at hand, we now target three additional questions. First, we apply the extensively used approximation of a rigid shift as a gate voltage to screen the IETS on a fine grid of gate ($V_g$) and source-drain bias ($V_{SD}$) voltages. This enable us to evaluate how close to the resonance we need to gate before strong IETS appears. Second, we will apply the broadening from the electrode phonons in order to evaluate the robustness of the signals. Finally, we will include the self-consistent electronic structure obtained at a finite bias and gate doping, which is a quite demanding calculation but enables us to judge the importance of including the full self-consistent potential, which was so far neglected.

The computed IETS signals as a function of varying gate voltage are shown in Fig. 3(a) as a density plot. It illustrates how the IETS signal is largest for gate values where the transmission varies the most, i.e., at the resonance ($V_g \approx 0.6$ eV, vertical dashed line) and at the band edge ($V_g \approx 0.15$ eV). In addition, the signals are clearly present in a region of $\Delta V_g \approx \omega_p$ (up to 0.2 V) around the peak position. We conclude that the inelastic signals are only present when the Fermi-level position is tuned to gate values where electron transmission resonances are present. Therefore IETS and its variation with gate voltage will strongly indicate if sharp resonances are present in a nanostructured graphene device. The IETS spectra at $V_g \approx 0.6$ eV are shown in Fig. 3(b). So far the finite broadening in the vibrational signals was obtained from the finite temperature of $T = 4.2$ K. Other broadening mechanisms exist, e.g., originating from a lock-in modulation voltage [33] or coupling to the surrounding electrode phonon baths and anharmonic couplings. Table I contains the linear friction, giving the broadening due to the phonon bath for the characteristic modes. The friction is smallest for modes localized in the center of the constriction (e.g., M3 and M6) and larger for modes with displacements near the contacts (e.g., M1, M5, and M7). The largest phonon friction in the system is found to be $\eta_{phon} = 77$ meV for comparison for a mode that however does not couple significantly with the current. We find that the phonon broadening varies by three orders of magnitude in the range of $0.1 \text{--} 100$ meV between the different phonon modes.

In Fig. 3(b), we include the damping/broadening from the friction model, red dashed-dotted line obtained from Eq. (7), and the full phonon DOS, black solid line obtained from Eq. (9), and compare with the original signal, blue dashed line. We include the broadening from the electrode phonons as the convolution described in Eq. (8). Despite the broadening from electrode phonons we find robust fingerprint signatures. In addition, the difference in the broadening between the vibrational modes is clearly visible in the IETS signals. For instance, the signal around 0.08 and 0.2 eV (M1, M2, and M3) is found to be $\eta_{phon} = 77$ meV for comparison for a mode that however does not couple significantly with the current. We find that the phonon broadening varies by three orders of magnitude in the range of $0.1 \text{--} 100$ meV between the different phonon modes.

![Image](245415-4)

**FIG. 3.** (a) Inelastic vibrational signals in the LOE second derivative of the current as a function of gate $V_g$ and applied bias voltages $V_{SD}$. (b) Second derivative of the current at the specific gate value indicated by a dashed vertical line (on-resonance) in (a).

| TABLE I. The friction from phonon $\eta_{phon}$ and electron $\eta_e$ baths for the eight characteristic modes. |
|---|---|---|---|---|---|---|---|---|
| $\omega$ | $\eta_{phon}$ | $\eta_e$ |
| meV | M1 | M2 | M3 | M4 | M5 | M6 | M7 | M8 |
| 193 | 192 | 172 | 171 | 168 | 128 | 76 | 49 |
| 16.2 | 3.0 | 0.6 | 5.2 | 6.3 | 0.2 | 6.4 | 2.6 |
| 0.9 | 0.6 | 1.7 | 0.9 | 2.9 | 0.2 | 1.9 | 1.1 |
M7) is reduced significantly whereas most of the signals at 0.05, 0.128, and 0.17 eV (M8, M6, and M3–M5) survive. The frictional broadening model, cf. Eq. (7), exaggerates the broadening mechanism compared to the full line-shape model, cf. Eq. (7). Well-defined IETS signals using the more approximate friction model thus imply that these exist also for the more elaborate damping. However, M6 is reduced slightly more by the full line-shape model than the friction model.

The line shape itself can change due to the phonon broadening such that a dip-peak resembles more a peak when the phonon broadening is included, see for instance the highest frequency mode (M1). We conclude that the dominant inelastic vibrational signals occur for modes that at one time have a symmetry dictated by the electronic scattering states in Fig. 2(a) and at the same time are marginally localized near the electrodes so that the vibrational broadening from the electrode phonons is low [Fig. 2(c) and Table I].

We have also tried to apply a constant artificial broadening to all peaks to examine at what friction value the peaks start to vanish. We find that the first peaks get impossible to distinguish at a friction of approximately 5 meV whereas all peaks vanish at constant frictions above 10 meV. Both of these values are smaller than typical broadenings found in the system.

In Table I we for comparison list the damping due to electronic friction $\eta_e$, calculated from the method described in Ref. [6]. The electronic friction is in general strongly dependent on bias voltage and is here evaluated at the threshold voltage of $V_{SD} = \omega_p$. It is notably large for mode M5 and can for a few modes (M3 and M6) be on the same order of magnitude as the phonon friction. A few modes with a strong coupling to the current also obtain a large phonon friction relative to the electronic friction, i.e., M1 and M7. Interestingly, we find that $\eta_e$ decreases with $V_{SD}$ since the electronic structure away from the resonance comes into play. As a consequence the electronic friction may play a more dominant role as broadening near a resonance, whereas it can be tuned with the applied bias voltage. In a previous study we calculated the current-induced forces and heating in the GNC system. We note that the modes here giving the largest IETS signal in the current are different from the modes which we have found to yield a highly nonlinear heating at bias voltages above 0.4 V and which are related to a current induced and can give rise to negative electronic friction for certain “run-away” modes [6].

In Fig. 4 we include the self-consistent electronic structure obtained at a finite bias and an electrostatic gate. The electrostatic gate is modeled by adding a charge $q$ on a plane 20 Å below the system and $-q$ to the device generating an electric field. For a detailed discussion of the gating model and the potential drop we refer the reader to Ref. [53]. Here, we focus on the main signal near resonance. Increasing the bias voltage in the DFT-NEGF simulation ($V_{SD} = 0.25$ V and $q = 0$), hereby including the potential drop in the electronic structure, introduces a slight shift in the signal position with respect to $V_g$ but does not influence its magnitude. Changing the charge of the system separately ($V_{SD} = 0$ V and $q = -2e$) is observed to move the location of the signal almost 0.2 eV. Including both charge and bias voltage ($V_{SD} = 0.25$ V and $q = -2e$) does to some extent break the symmetry of the IETS signals, but the magnitude and the dominating modes are unaffected.

IV. CONCLUSIONS

To summarize, we have presented the calculations of inelastic vibrational signals in GNCs where the phonon broadening and high phonon frequencies necessitate extended methodology. First-principles calculations of the inelastic vibrational signals in the current can include the electrode phonon broadening through a postprocessing for each vibrational mode. In particular, we find that the broadening from the electrode phonons can vary by up to three orders of magnitude between the vibrational modes. We find several strong inelastic signals for Fermi-level positions close to electron transmission resonances which are robust against finite-bias effects as well as broadening from the electrode phonons. Therefore, inelastic signals depending on gate voltage can be used to investigate if sharp electron transmission resonances are present in a nanostructured graphene device. The propensity rules dictate that the dominant inelastic vibrational signals occur for modes that both have a symmetry coinciding with that of the electronic scattering states and at the same time are marginally localized near the electrodes so that the vibrational broadening from the electrode phonons is low.

ACKNOWLEDGMENTS

The authors acknowledge support from Innovation Fund Denmark, Grant Nano-Scale Design Tools for the Semiconductor Industry (Grant No. 79-2013-1). The Center for Nanostructured Graphene (CNG) is sponsored by the Danish National Research Foundation, Project No. DNRF103.

[52] It is also possible to define a friction from the phonon self-energy at the mode frequency instead: 
\[ \eta_{\text{ph}} = -\text{Im}[\Sigma_{\text{ph}}^\omega(\omega = \omega_0)]/\omega_0. \]
However, we find that this approximation underestimates the DOS significantly, and we will not discuss this model any further. Friction models further neglect the real part of the self-energy and the corresponding mode-mode coupling and derived frequency shifts.